

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Pelham and Burr

Serial: 10/772,029

Group Art Unit: 2818

Filed: February 3, 2004

Examiner: Luu, C. A.

For: METHOD FOR GENERATING A DEEP N-WELL PATTERN FOR  
AN INTEGRATED CIRCUIT DESIGN

Honorable Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

RESPONSE

Dear Sir:

In response to the non-final Official Action mailed November 14, 2007 in the above captioned case, Applicants respectfully request the Examiner to consider the following remarks. Immediately after this transmittal page is the Applicant Argument (or Remarks).